## What is claimed is:

- 1 1. A fuel cell separator that has a substrate made of a first
- 2 metal, comprising:
- 3 a metal layer formed on a surface of the substrate, the
- 4 metal layer being made of a second metal that is different from
- 5 the first metal in composition;
- a conductive porous layer formed on a surface of the metal
- 7 layer, the conductive porous layer being made up of a plurality
- 8 of conductive particles which are fusion-bonded to each other;
- 9 and
- an oxide film formed on parts of the surface of the metal
- 11 layer that do not come into contact with the conductive
- 12 particles, the oxide film having a higher corrosion resistance
- 13 than the substrate.
- 1 2. The fuel cell separator of Claim 1,
- wherein the oxide film is formed by oxidizing the metal layer,
- $3\,$  so that the oxide film is oxidized by a greater degree than a
- 4 surface of the metal layer at an interface between the
- 5 conductive particles and the metal layer.
- 1 3. The fuel cell separator of Claim 1,
- wherein the metal layer is made of a material that has a

- 3 higher conductivity than the substrate.
- 1 4. The fuel cell separator of Claim 1,
- wherein the conductive porous layer is made of a material
- 3 that has a higher conductivity than the substrate.
- 1 5. The fuel cell separator of Claim 4,
- 2 wherein ribs and channels are formed on at least one
- 3 principal surface of the substrate, and the conductive porous
- 4 layer is adhered to upper surfaces of the ribs.
- 1 6. The fuel cell separator of Claim 1,
- 2 wherein the first metal is selected from the group
- 3 consisting of stainless steel, aluminum and aluminum alloy.
- 1 7. The fuel cell separator of Claim 1,
- wherein the second metal is one of Cr and a Cr alloy
- 3 containing at least 20wt% of Cr.
- 1 8. The fuel cell separator of Claim 7,
- 2 wherein the Cr alloy contains at least one element selected
- 3 from the group consisting of Ni, Ti, Nb, Au and Pt.
- 1 9. The fuel cell separator of Claim 1,

- wherein the conductive porous layer is made of a metal
- 3 containing at least one element selected from the group
- 4 consisting of Ni, Ti, Nb, Au and Pt.
- 1 10. A fuel cell having an anode on one surface of an
- 2 electrolytic film, a cathode on a remaining surface of the
- 3 electrolytic film, a separator being opposed to the anode, and
- 4 a separator being opposed to the cathode, wherein the fuel cell
- $oldsymbol{5}$  generates power from a fuel and an oxidizer when the fuel is
- 6 distributed along a surface of the separator facing the anode
- 7 and the oxidizer is distributed along a surface of the separator
- 8 facing the cathode,
- 9 wherein the separator is any one of the fuel cell
- 10 separators of Claims 1 to 9.
- 1 11. A manufacturing method for a fuel cell separator having
- 2 a metal substrate, comprising:
- a metal layer forming step for forming a metal layer on
- 4 a surface of the substrate, the metal layer serving as an oxide
- 5 film that has a higher corrosion resistance than the substrate;
- a conductive layer forming step for forming a porous
- 7 conductive layer on a surface of the metal layer, the porous
- 8 conductive layer being made up of a plurality of conductive
- 9 particles which are fusion-bonded to each other, the plurality

- 10 of conductive particles having a higher conductivity than the
- 11 substrate;
- 12 an oxidizing step for oxidizing exposed parts of the
- 13 surfaces of the metal layer and the conductive particles; and
- 14 a removing step for removing oxides from the exposed parts
- 15 of the surfaces of the conductive particles.
- 1 12. The manufacturing method of Claim 11,
- wherein the metal layer forming step produces the metal
- 3 layer by physical vapor deposition.
- 1 13. The manufacturing method of Claim 12,
- wherein a target substance used for the physical vapor
- 3 deposition has a higher corrosion resistance than the substrate
- 4 when it is oxidized.
- 1 14. The manufacturing method of Claim 11,
- wherein the conductive layer forming step produces the
- 3 porous conductive layer by physical vapor deposition.
- 1 15. The manufacturing method of any one of Claims 12 to 14,
- wherein the physical vapor deposition is an arc ion
- 3 plating method.

- 1 16. The manufacturing method of Claim 11,
- 2 wherein the removing step includes the usage of an arc
- 3 ion plating apparatus to remove the oxides by performing
- 4 bombardment with an inert gas.